Ref	Hits	Search Query	DBs	Default	Plurals	Time Stamp
#	nis	Search Query	<i>D</i>	Operator		
L1	3	09/712389	USPAT	OR	ON	2005/05/07 14:59
L2	1	("6413145").PN.	USPAT	OR	OFF	2005/05/07 14:59
L3	1	("6261152").PN.	USPAT	OR	OFF	2005/05/07 15:00
L4	1	2 and (polishing or mechanical or chemical or metrology or station or parameter or thickness or dielectric or insulating or wafer or substate or subsequent or erosion or plurality reference or solution or measuring or calculating or uniform metal or apparatus or chamber or cleaner)	USPAT	OR	ON	2005/05/07 15:06
L5	1	3 and (polishing or mechanical or chemical or metrology or station or parameter or thickness or dielectric or insulating or wafer or substate or subsequent or erosion or plurality reference or solution or measuring or calculating or uniform metal or apparatus or chamber or cleaner)	USPAT	OR	ON	2005/05/07 15:13
L6	3	1 and (polishing or mechanical or chemical or metrology or station or parameter or thickness or dielectric or insulating or wafer or substate or subsequent or erosion or plurality reference or solution or measuring or calculating or uniform metal or apparatus or chamber or cleaner)	USPAT	OR	ON	2005/05/07 15:11
L7	39	(polishing adj parameter) and CMP and metrology and dielectric and thickness	USPAT	OR	ON	2005/05/07 15:12
L8	24	(polishing adj parameter) and CMP and metrology and dielectric and thickness and erosion	USPAT	OR .	ON	2005/05/07 15:12
L9	14	(polishing adj parameter) and CMP and metrology and dielectric and thickness and erosion and station and measurement	USPAT	OR	ÓN	2005/05/07 15:13
L10	14	9 and (polishing or mechanical or chemical or metrology or station or parameter or thickness or dielectric or insulating or wafer or substate or subsequent or erosion or plurality reference or solution or measuring or calculating or uniform metal or apparatus or chamber or cleaner)	USPAT	OR	ON	2005/05/07 15:27

L11	869	438/690	USPAT	OR	ON	2005/05/07 15:26
L12	1413	438/691	USPAT	OR	ON	2005/05/07 15:26
L13	3416	438/692	USPAT	OR	ON	2005/05/07 15:26
L14	666	438/697	USPAT	OR	ON	2005/05/07 15:26
L15	1860	438/687	USPAT	OR	ON	2005/05/07 15:26
L16	1169	438/689	USPAT	OR	ON	2005/05/07 15:27
L17	552	438/740	USPAT	OR	ON	2005/05/07 15:27
L18	334	438/905	USPAT	OR	ON	2005/05/07 15:27
L19	533	438/906	USPAT	OR	ON	2005/05/07 15:27
L20	1	("6857947").PN.	USPAT	OR	OFF	2005/05/07 15:27
L21	1	20 and (polishing or mechanical or chemical or metrology or station or parameter or thickness or dielectric or insulating or wafer or substate or subsequent or erosion or plurality reference or solution or measuring or calculating or uniform metal or apparatus or chamber or cleaner)	USPAT	OR	ON	2005/05/07 15:30
L22	1	("6829054").PN.	USPAT	OR	OFF	2005/05/07 15:27
L23	1	22 and (polishing or mechanical or chemical or metrology or station or parameter or thickness or dielectric or insulating or wafer or substate or subsequent or erosion or plurality reference or solution or measuring or calculating or uniform metal or apparatus or chamber or cleaner)	USPAT	OR	ON	2005/05/07 15:27
L24	1	("6413145").PN.	USPAT	OR	OFF	2005/05/07 15:30
L25		24 and (polishing or mechanical or chemical or metrology or station or parameter or thickness or dielectric or insulating or wafer or substate or subsequent or erosion or plurality reference or solution or measuring or calculating or uniform metal or apparatus or chamber or cleaner)	USPAT	OR	ON	2005/05/07 15:30